

	Class	Subclass

PATENT NUMBER

U.S. UTILITY Patent Application

<i>Edi</i> O.I.P.E. SCANNED <i>TR4</i> G.A. <i>rw</i>	PATENT DATE
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APPLICATION NO. 09/866990	CONT/PRIOR F	CLASS 525	SUBCLASS 1	ART UNIT 1711	EXAMINER
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APPLICANTS

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TITLE

Process for production of polystyrene resin film by heating
thin film process for producing process bath, iodine salt and
apparatus for forming same.

PTO-2040
12/99[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drawn	Figs. Drawn	Print Fig.	Total Claims
The term of this patent subsequent to _____ (date) has been disclaimed	Assessed Examination _____ Date _____		NOTICE OF ALLOWANCE MAILED	
	The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____			
ISSUE FEE				
Amount Due			Date Paid	
The terminal _____ months of this patent have been disclaimed	Assessed Examination _____ Date _____		ISSUE BATCH NUMBER	
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